

IN THE CLAIMS

1. A non-wax glass polishing composition comprising:

- a) a water-repelling and film-forming acrylic resin;
- b) silicone fluid;
- c) finely divided titanium dioxide abrasive;
- d) a hydrocarbon solvent;
- e) an alkanol solvent;
- f) acrylic polymer; and
- g) water

2. The polishing composition of Claim 1 further containing a preservative.

3. The polishing composition of Claim 1 further containing a fragrance.

4. The polishing composition of Claim 1 wherein:

the acrylic ^{resin} polymer comprises from about 0.6% to about 2.5% by weight of the polishing composition;

the silicone fluid comprises from about 4% to about 8% by weight of the polishing composition;

the abrasive comprises from about 1% to about 6% by weight of the polishing composition;

the hydrocarbon solvent comprises from about 5% to about 25% by weight of the polishing composition;

the alkanol solvent comprises from about 2% to about 5% of the polishing composition;

the acrylic polymer comprises from about 1.2% to about 2% by weight of the polishing composition; and

the water comprises the remainder of the polishing composition.

5. The polishing composition of Claim 1 wherein:

the acrylic polymer comprises from about 1.3% to about 1.8% by weight of the polishing composition;

the silicone fluid comprises from about 4% to about 6% by weight of the polishing composition;

a1
CMT the abrasive comprises from about 2% to about 3.5% by weight of the polishing composition;

the hydrocarbon solvent comprises from about 8% to about 13% by weight of the polishing composition;

the alkanol solvent comprises from about 2% to about 5% of the polishing composition;

the acrylic polymer comprises from about 1.2% to about 2% by weight of the polishing composition; and

the water comprises the remainder of the polishing composition;

IN THE TITLE

Page 1, line 3:

a2 NON-WAX SUPERIOR GLOSS POLISHING COMPOSITION

IN THE SPECIFICATION

Page 5, starting at line 10, Example II:

EXAMPLE II

The polishing composition was prepared by mixing the following ingredients according to the procedure of Example I.

a3

Ingredient	% by weight
Deionized water	QS
Dye	0.007
Acusol 820	1.700
Caustic soda 50% solution	0.197
Kaopolite 1168	2.000
Titanium dioxide	2.500
Preservative	0.100
Silicone SWS 101, 350 cst	2.000
Silicone SWS 101, 1000 cst	1.000
Silicone SWS 101, 30,000 cst	0.300
Amino-silicone F=784	1.500
Odorless Mineral Spirits	10.500

EXAMPLE III

The polishing composition was used for the comparative tests was prepared by mixing the following ingredients according to the procedure of Example I.

a4

Ingredient	% by weight
Deionized water	QS
Dye	0.007
Acusol 820	1.600
Caustic soda 50% solution	0.195
Kaopolite 1168	2.000
Titanium dioxide	2.700
Preservative	0.100
Silicone SWS 101, 350 cst	2.000
Silicone SWS 101, 1000 cst	0.940
Silicone SWS 101, 30,000 cst	0.300
Amino-silicone F=784	1.000
Odorless Mineral Spirits	9.350
Isopropanol	4.200
Acrylic resin	1.500
Fragrance	0.100
Total	100.00